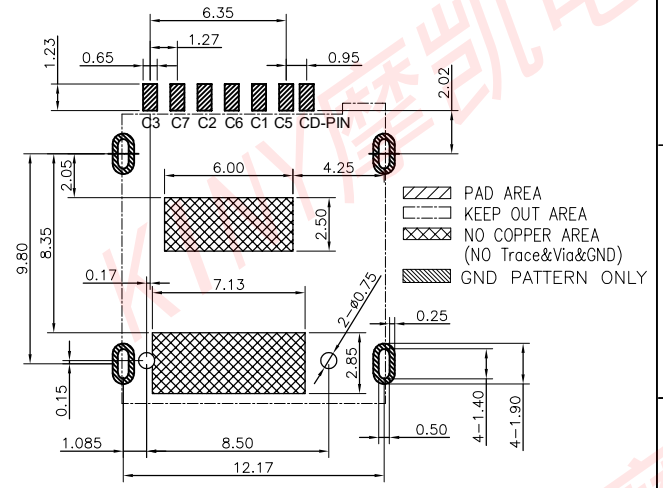
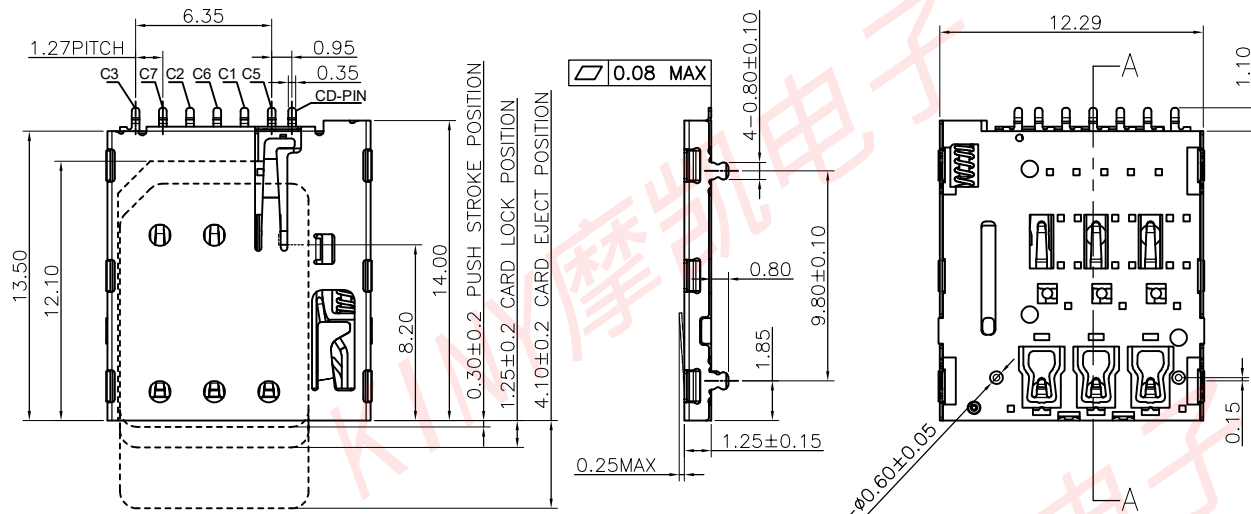
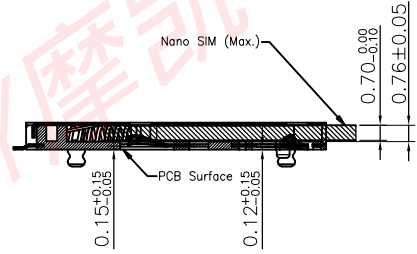
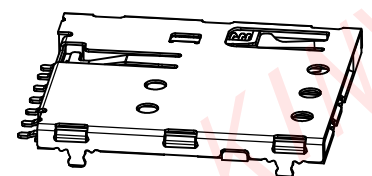
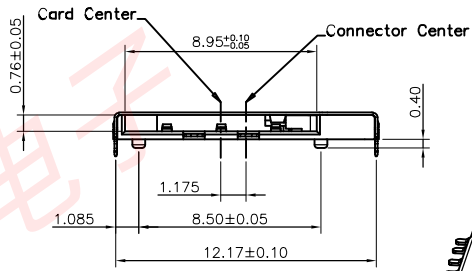


* 所有原料材质, 生产制程, 电镀必须符合HTR要求



RECOMMEND P.C.B LAYOUT
(General tolerance ±0.05)

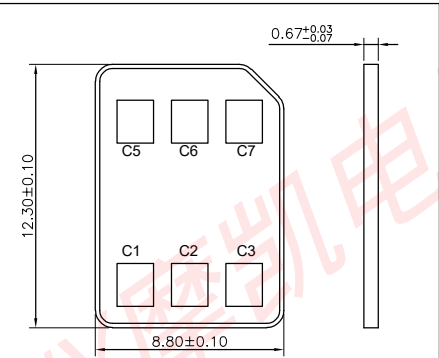
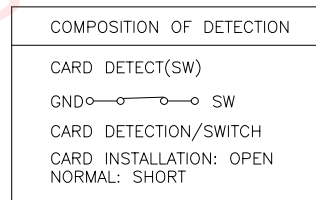


Section A-A

- NOTE:
- Material:
 - 1-1 Housing: High Temperature Thermoplastic, (LCP S475) Color Black UL 94V-0
 - 1-2 Contact: Phosphor Bronze (C5210R-H, T=0.12±0.01mm)
 - 1-3 Cover: SUS304-H T=0.12±0.03mm
 - Plating:
 - 2-1 Contact terminal:
 - Contact area: Gold FLASH.
 - Solder area: Sn 120u" Min.
 - Underplating: Ni overall 50U" Min.
 - 2-2 Cover:
 - Underplating: Ni overall 50U" Min.
 - Specification:
 - 3-1. Current Rating :0.5A max.
 - 3-2. Contact Resistance: 50 mOhms max
 - 3-3. Insulation Resistance: 1000 MOhms min./500VDC
 - 3-4. Dielectric Withstanding Voltage: 500 V AC/1minute
 - 3-5. Operating Temperature: -25°C to +85°C
 - 3-6. Mating Cycles: 5000 Insertions

SIM Card Pin Assignments

NANO SIM CARD	
C1	Vcc
C2	RST
C3	CLK
C5	GND
CD	CD/SW
C6	Vpp
C7	I/O



A	---	NEW RELEASE	Janyz	2019.08.23
REVISION NO.	ECR NO.	DESCRIPTION	MARK	DATE
1				

东莞市摩凯电子有限公司

DIMENSIONS INIT: mm UNLESS OTHERWISE SPECIFIABLE DIMENSION TOLERANCE X.X: ± 0.35 X.XX: ± 0.20 X.XXX: ± 0.10 ANGULAR: ± 2'	PRODUCT NAME : NANO SIM H1.25 PUSH/PUSH	DRAWING: Janyz	DATE: 2019.08.23
	PRODUCT NO. : NS125-T1250-01	CHECK: Alex	DATE: 2019.08.23
	DRAWING NO. : D-NS125-T1250-01	APPROVED: Alex	DATE: 2019.08.23
		SCALE: 1:1	DWG ID: C D
		REV.: A	PAGE: 1 OF 1